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	FORM		First Named Inventor	Rajen	ndran Nair		
(to	be used for all correspondence after initial	filing)	Art Unit	2814			
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	Fee Transmittal Form (2 copies)  Fee Attached  Amendment/Reply  After Final  Affidavits/declaration(s)  Extension of Time Request  Express Abandonment Request  Information Disclosure Statement  Certified Copy of Priority  Document(s)  Response to Missing Parts/ Incomplete Application  Response to Missing Parts  under 37 CFR 1.52 or 1.53		Drawing(s) Licensing-related Papers Petition Petition to Convert to a Provisional Application Power of Attorney, Revocation Change of Correspondence Addr Terminal Disclaimer Request for Refund CD, Number of CD(s)	ress	to Technol Appeal Co of Appeal Appeal Co (Appeal No Proprietar  Status Le	closure(s) (please	
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This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to 12 minutes to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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# **EE TRANSMITTAL** for FY 2004

Effective 10/01/2003. Patent fees are subject to annual revision.

Applicant claims small entity status. See 37 CFR 1.27

(\$) 330.00 TOTAL AMOUNT OF PAYMENT

Complete if Known				
Application Number	09/677,698			
Filing Date	September 28, 2000			
First Named Inventor	Rajendran Nair	·		
Examiner Name	Shrinivas H. Rao			
Art Unit	2814			
Attorney Docket No.	42390.P9239			

Check	METHOD OF PAYMENT (check all that apply)	FEE CALCULATION (continued)					
□		3. ADDITIONAL FEES					
Deposit   O2-2666   Deposit   O2-2666   Deposit   Number   Deposit   Number   Deposit   Number   Deposit   Account   Number   Deposit   Account   Deposit		<u>Large</u> E	ntity	Small	Entity		
Number   Deposit   Account   Substitution   Subs	Deposit					Fee Description	Fee Paid
Account Name The Director is authorized to: (check all that apply) Charge fee(s) indicated below	Number	1051	130	2051	65	Surcharge - late filing fee or oath	
The Director is authorized to: (check all that apply) Charge fee(s) indicated below	Account Blakely, Sokoloff, Taylor & Zafman LLP	1052	50	2052			
Charge fee(s) indicated below		1053	130	1053	130	Non-English specification	
Charge any additional tee(s) or any underpayment of tee(s)		1812	2,520	1812	2,520	For filing a request for ex parte reexamination	ļ
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Total Claims		1501	1,330	2501			
Independent Claims :  Multiple Dependent  Large Entity   Small Entity   Fee   Fee   Fee   Fee   Fee   Fee   Fee   Code (\$)    1202   18   2202   9   Claims in excess of 20    1201   86   2201   43   Independent claims in excess of 3    1203   290   2203   145   Multiple dependent claims in excess of 3    1204   86   2204   43   ** Reissue independent claims over original patent    1205   18   2205   9   ** Reissue claims in excess of 20    1205   18   2205   9   ** Reissue claims in excess of 20    1206   1807   50   Processing fee under 37 CFR 1.17(q)    1807   50   Processing fee under 37 CFR 1.17(q)    1808   1809   1800   1800   1800   Submission of Information Disclosure Stmt    8021   40   8021   40   Recording each patent assignment per property (times number of properties)    1809   770   2809   385   Filing a submission after final rejection (37 CFR 1.129(a))    1809   770   2810   385   For each additional invention to be examined (37 CFR 1.129(b))    1801   770   2801   385   Request for Continued Examination of a design application    1801   770   2801   385   Request for expedited examination of a design application    1809   770   2801   385   Request for expedited examination of a design application    1800   770   2801   385   Request for expedited examination of a design application    1801   770   2801   385   Request for expedited examination of a design application    1801   770   2801   385   Request for expedited examination of a design application	Extra Claims below Fee Paid	1502	480	2502			
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Large Entity   Small Entity   Fee Fee Code (\$)   Fee Description   1807   50   1807   50   Processing fee under 37 CFR 1.17(q)   1806   180   Submission of Information Disclosure Stmt   1807   Submission of Information Disclosure Stmt   1807   Submission of Information Disclosure Stmt   1808	Claims ;	1460	130	1460	130	Petitions to the Commissioner	
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Registration No. Name (Print/Type) Dennis A. Nicholls 42.036 Telephone 408-720-8300 (Attomev/Agent) a Date March 25, 2004 Signature

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MAR 2 9 2004 W Socket No.: 42390.P9239

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE BOARD OF PATENT APPEALS AND INTERFERENCES

In re the ap	plication of:	)
Nair, F	Rajendran, et al.	)
Serial No.:	09/677,698	) Examiner: Rao, S.
Filed:	09/28/ 2000	) Art Unit: 2814
	HOD AND APPARATUS FOR K INVERSION MODE MOS	)
DEC	OUPLING CAPACITOR	)

### APPELLANTS' BRIEF UNDER 37 CFR § 1.192 IN SUPPORT OF APPELLANTS' APPEAL TO THE BOARD OF PATENT APPEALS AND INTERFERENCES

#### (REVISED)

Hon. Commissioner for Patents Mail Stop Appeal Brief – Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Appellants hereby submit this Brief in triplicate in support of an appeal from a final decision of the Examiner, in the above-referenced case. Appellants respectfully request consideration of this appeal by the Board of Patent Appeals and Interference for allowance of the above-

referenced patent application.

03/30/2004 FFANAEIA 00000015 09677698

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# TABLE OF CONTENTS

I.	REAL PARTY IN INTEREST	3
II.	RELATED APPEALS AND INTERFERENCES	3
III.	STATUS OF THE CLAIMS	3
IV.	STATUS OF AMENDMENTS	4
v.	SUMMARY OF THE INVENTION	5
VI.	ISSUES	6
VII.	. GROUPING OF CLAIMS	6
	I. ARGUMENT	
IX.	APPENDIX:	18

#### I. Real Party in Interest

The real party in interest in the present appeal is Intel Corporation, a Delaware Corporation headquartered in Santa Clara, California, the assignee of the present application.

#### II. Related Appeals and Interferences

There are no related appeals or interferences to appellants' knowledge that would have a bearing on any decision of the Board of Patent Appeals and Interferences.

## III. Status of the Claims

Claims 2 through 7 and 20 through 23 stand rejected under 35 U.S.C. 103 over Stein et al. (U.S. Patent No. 4,055,837, hereinafter *Stein*) and Howard (U.S. Patent No. 4,437,139, hereinafter *Howard*) and Dawson et al. (U.S. Patent No. 5,851,891, hereinafter *Dawson*).

#### IV. Status of Amendments

A first Office Action in the present application was mailed 11/05/2001. A first response with amendment was submitted by the appellants on 03/05/2002, and the amendment was entered. In response to appellants' first response with amendment, an Office Action with a Final Rejection was mailed 06/11/02. Appellants responded by submitting a Request for Continued Examination with amendment on 09/11/2002.

A non-final Office Action was mailed on 11/29/2002. Appellants responded by submitting a response with amendment on 02/28/2003. An Office Action with a Final Rejection was mailed 06/04/2003. Appellants filed a Notice of Appeal on 10/03/2003.

Appellants submitted on 11/19/2003 an original Appeal Brief and an amendment after final rejection under 37 CFR 1.116(b). An Advisory Action/Notice of Defective Brief was mailed on 02/27/2004 which stated that the amendment after final rejection would not be entered, and that therefore the original Appeal Brief was defective.

Appellants therefore submit the present revised Appeal Brief, including the claims as presented in the response with amendment of 02/28/2003.

#### V. Summary of the Invention

Appellants' disclosure describes a method and apparatus for improvements in a MOS transistor for use in as a decoupling capacitor in an integrated circuit. It is generally possible to connect a MOS transistor as a decoupling capacitor in two ways: connect the gate electrode to the minus power supply trace ("strong inversion mode") or connect the gate electrode to the positive power supply trace ("depletion mode"). This is shown in Figures 2 and 3, respectively. Generally the strong inversion mode configuration has proven the better of the two until recently. As the gate oxide layers have become thinner, leakage currents have become substantial.

Appellants' disclosure describes certain modifications in the structures and materials used in the fabrication of a MOS transistor that permit its use as a superior decoupling capacitor when used in the "depletion mode" circuit configuration. Generally this entails using a diffused gate region material with a reduced work function. Another modification that may be used is to heavily dope the substrate area. One embodiment's MOS transistor is shown in Figure 5, where the gate region 510 is fabricated from platinum silicide (PtSi). Other materials are also disclosed. See specification page 7 line 23 through page 8 line 4. When such a MOS transistor is connected in the "depletion mode" configuration, its performance may justify calling it a "weak inversion mode" capacitor as shown in Figure 6. The Figure 5 MOS transistor when configured as in Figure 6 has superior capacitance-to-voltage characteristics as shown in Figures 7 and 8. Specifically, curve 720 of Figure 7 shows how the "weak"

inversion mode" capacitor actually increases in capacitance as the supply voltage decreases, an advantageous property for a decoupling capacitor.

#### VI. Issues

1. Whether claims 2 through 7 and 20 through 23 are unpatentable under 35 U.S.C. 103 over Stein et al. (U.S. Patent No. 4,055,837) and Howard (U.S. Patent No. 4,437,139) and Dawson et al. (U.S. Patent No. 5,851,891).

## VII. Grouping of Claims (Independent Claims Bolded)

 $\underline{Group\ I}\hbox{:}\ Decoupling\ Capacitor$ 

For the purposes of this appeal claims **2**, 3, 4, 5, 6, 7, **20**, 21, 22, and 23 stand or fall together.

#### VIII. Argument

# A. Claims 2 – 7 and 20 - 23 Are Not Obvious In View of Stein, Howard, and Dawson

Claims 2 through 7 and 20 through 23 stand rejected under 35 U.S.C. 103 over Stein et al. (U.S. Patent No. 4,055,837, hereinafter *Stein*) and Howard (U.S. Patent No. 4,437,139, hereinafter *Howard*) and Dawson et al. (U.S. Patent No. 5,851,891, hereinafter *Dawson*).

To establish a *prima facie* case of obviousness, case law as cited in the MPEP requires three criteria.

First, there must be some suggestion or motivation, either in the references themselves or in the knowledge generally available to one of ordinary skill in the art, to modify the reference or to combine reference teachings. Second, there must be a reasonable expectation of success. Finally, the prior art reference (or references when combined) must teach or suggest all the claim limitations. The teaching or suggestion to make the claimed combination and the reasonable expectation of success must both be found in the prior art and not based on applicant's disclosure. *In re Vaeck*, 947 F.2d 488, 20 USPQ2d 1438 (Fed. Cir. 1991). MPEP § 706.02(j).

Moreover, the Federal Circuit has recently cautioned that the Patent Office must support its rejections for reasons that are stated on the record that establish why a particular combination would have been motivated by the prior art. It is inadequate to just state in conclusory fashion that just because two elements existed in the prior art, that

someone should have or would have been motivated to combine them. A specific teaching or a specific principle must be stated that makes the combination obvious.

The need for specificity pervades this authority. See, e.g., In re Kotzab, 217 F.3d 1365, 1371, 55 USPQ2d 1313, 1317 (Fed. Cir. 2000) ("particular findings must be made as to the reason the skilled artisan, with no knowledge of the claimed invention, would have selected these components for combination in the manner claimed"); In re Rouffet, 149 F.3d 1350, 1359, 47 USPQ2d 1453, 1459 (Fed. Cir. 1998) ("even when the level of skill in the art is high, the Board must identify specifically the principle, known to one of ordinary skill, that suggests the claimed combination. In other words, the Board must explain the reasons one of ordinary skill in the art would have been motivated to select the references and to combine them to render the claimed invention obvious."); In re Fritch, 972 F.2d 1260, 1265, 23 USPQ2d 1780, 1783 (Fed. Cir. 1992) (the examiner can satisfy the burden of showing obviousness of the combination "only by showing some objective teaching in the prior art or that knowledge generally available to one of ordinary skill in the art would lead that individual to combine the relevant teachings of the references"). In re Sang Su Lee, 277 F.3d 1338, 61 USPQ 1430 (Fed. Cir. 2002).

Appellants submit that (a) no specific showing of motivation to combine the references has been provided, and (b) that the references, even if combined, do not provide the claimed invention.

### a. No Specific Showing of Motivation to Combine

The contention in the Final Office Action that it would be obvious to combine *Stein*, *Howard*, and *Dawson* is both legally and factually erroneous.

#### i. Factually, Stein does not suggest

Stein teaches a cell for use in non-volatile memory, including a MOS transistor 1 and a metal-nitride-oxide-semiconductor (MNOS)

capacitor 2 of Figures 1 and 3. The MOS transistor 1 of *Stein* is not connected as a decoupling capacitor as per the present invention: instead, the MOS transistor 1 of *Stein* is connected as an active switching device whose gate electrode is connected to a word line 10. Any special capacitance disclosed in *Stein* is embodied in MNOS capacitor 2. A MNOS capacitor is not a MOS transistor and hence is irrelevant to the present claimed invention. Enhancing the structure of MOS transistor 1 for use as a decoupling capacitor is not at issue in *Stein*, hence there is no intrinsic teaching that such enhancements would be useful.

The entirety of the explanation from the Office Action of why a MOS transistor with any desired gate work function should be added to *Stein* reads as follows:

Therefore it would have been obvious to one of ordinary skill in the art at the time of the invention to make Stein's device with any desired gate work function as described by Dawson. (Dawson col. 2 line 49, Dawson in col. 4 lines 52-67 and col. 5 lines 1-15 also describes diffused gate material).

Final Office Action dated 06/04/2003, Page 4.

The Office Action makes no explanation whatsoever as to why the use of the chemical compounds purportedly disclosed in *Howard* would be useful when added to the MOS transistor 1 of *Stein*. As mentioned above, enhancing the structure of MOS transistor 1 for use as a decoupling capacitor is not at issue in *Stein*, hence there is no intrinsic teaching that such enhancements would be useful.

#### ii. Legally, burden not met

Furthermore, appellants submit that the evidentiary burden for an obviousness rejection has not been met. The Federal Circuit was specific in its admonitions in In re Sang Su Lee. Particular factual findings are required to underpin a §103 rejection. Here, the Final Office Action only makes the conclusory statement that "[t]herefore it would have been obvious to one of ordinary skill in the art at the time of the invention to make Stein's device with any desired gate work function as described by Dawson. (Dawson col. 2 line 49, Dawson in col. 4 lines 52-67 and col. 5 lines 1-15 also describes diffused gate material)."

No factual basis is given as to why someone would be motivated to add modifications to the MOS transistor of *Stein*, particularly in view of the fact that *Stein* used the MOS transistor 1 as an active switch controlled by a memory word line 10. What is the motivating factor? Moreover, motivation to combine the purported work function of *Dawson* or the PtSi of *Howard* to the MOS transistor of *Stein* as claimed in the present application is necessary. Without an evidentiary basis upon which to draw this conclusion, the conclusion cannot stand.

# b. Even if Combined, *Stein, Howard*, and *Dawson* Do Not Meet the Claim Limitations

#### i. Group I

As discussed above, appellants submit that insufficient motivation exists to combine the *Stein*, *Howard*, and *Dawson* references. Even assuming, however, that such a combination is made, the combination itself does not include all of the elements and limitations of appellants' claims.

Claim 2 stands rejected as being anticipated by *Stein* and *Dawson*. The MOS transistor 1 of *Stein* discloses no "metallic gate electrode coupled to a .....positive voltage source" as recited in pertinent part in claim 2. Instead, the MOS transistor 1 of *Stein* is connected to a memory word line 10, which is a signal trace and not a power supply trace connected to a positive voltage source.

Claim 2 further recites in pertinent part "wherein said metal-oxide-semiconductor transistor includes the diffused gate region formed from material with a work function less than – 0.56 volts." In the Office Action, it is stated that "Dawson in col. 2 lines 48-50 describes the formation of IGFETs with any desired gate work function to form devices with low gate resistances." However, appellants have not found any such technical disclosure in *Dawson*. *Dawson* col. 2 lines 48-50 actually

recites "Accordingly, a need exists for a method of fabricating an IGFET that provides a low resistivity gate with the desired work function."

(Appellants' emphasis added.) Appellants submit that this statement of a need existing is not an enabling disclosure of forming a gate with any particular work function. The only other use of the expression "work function" in Dawson occurs at col. 2, lines 19-20, which recites "Polysilicon, on the other hand, has a known work function..." And appellants' claimed invention is a replacement for the prior-art polysilicon used in a gate.

Claim 2 further recites in pertinent part "metallic source electrode and a metallic drain electrode coupled ... to each other and to a negative voltage source." Neither the MOS transistor 1 of *Stein* nor the various MOS transistors of *Dawson* show the drain connected to the source and both then connected to a negative voltage source. Indeed the MOS transistor 1 of *Stein* could not perform its switching function were this to be true.

Appellants submit that *Stein* and *Dawson* considered together do not disclose all of the claim elements and limitations of present claim 2. Therefore appellants submit that the invention claimed in claim 2 is not anticipated by *Stein* and *Dawson*, and therefore that claim 2 is allowable over the prior art of record.

Claim 3 stands rejected as being anticipated by, among others,

Howard. In the Office Action, a reference is made to Howard col. 3, line 31. However, appellants point out that the only place where Howard cites the use of platinum silicate (PtSi) is as part of bottom electrode 13, directly or indirectly coupled to the substrate 11. Howard does not show the use of platinum silicate as a "material of said diffused gate region" as recited in claim 3. Indeed, Howard only shows the use of platinum silicate in a bottom electrode 13 of a multi-layer capacitor 10 of Figure 1, not as a gate of a MOSFET. The multi-layer capacitor 10 of Howard requires a complicated dual-layer (or triple-layer) dialectric 14 consisting of a leakage prevention layer 18 and a high dielectric layer 17. This usage in *Howard* would if anything teach away from the use of platinum silicate in a more simple structure as disclosed in claim 3 of the present application. Because Howard does not teach the use of platinum silicate in a diffused gate region, and further because claim 3 depends from allowable claim 2, appellants submit that claim 3 is allowable over the prior art of record.

Claim 4 stands rejected as being anticipated by, among others, *Howard*. The Office Action states that the chemical compounds or elements tantalum nitrate (TaN), iridium (Ir), nickel (Ni), and arsenic (As) are disclosed in *Howard* at col. 3, lines 30-34. Appellants have downloaded a softcopy of *Howard* and performed word searches, but cannot find any reference to *any* of these compounds or elements in

Howard. Therefore appellants submit that the claimed invention of claim 4 is not anticipated by *Howard*. Since claim 4 depends from allowable claim 2, and further since claim 4 is not anticipated by *Howard*, appellants submit that claim 4 is allowable over the prior art of record.

Appellants point out that no separate rejections of claims 5, 6, and 7 were made in the Office Action. Appellants submit that claims 5, 6, and 7 are allowable as depending from allowable claim 2.

Claim 20 stands rejected as being anticipated by *Stein* and *Dawson*. Claim 20 recites in pertinent part "a metallic gate electrode to couple to a positive power supply voltage." In the Office Action, on page 4, it is stated that "Stein describes an apparatus including a metallic gate electrode to couple to a positive power supply voltage (Stein fig. 2)." Appellants again point out that the MOS transistor 1 of *Stein* has its gate electrode connected to the word line 10, which is a signal trace and not a power supply trace to couple to a positive power supply voltage.

Claim 20 further recites in pertinent part "a diffused gate region formed from a material whose work function is less than minus 0.56 volts." In the Office Action, again on page 4, it is stated that "Dawson in col. 2 lines 48-50 describes the formation of IGFETs with any desired gate work function to form devices with low gate resistances." As mentioned above in connection with claim 2, appellants have not found any such technical disclosure in *Dawson*. *Dawson* col. 2 lines 48-50

actually recites "Accordingly, a *need exists* for a method of fabricating an IGFET that provides a low resistivity gate with the desired *work function*." (Appellants' emphasis added.) Appellants submit that this statement of a *need existing* is not an enabling disclosure of forming a gate with any particular work function. The only other use of the expression "work function" in *Dawson* occurs at col. 2, lines 19-20, which recites "Polysilicon, on the other hand, has a *known work function*..." And appellants' claimed invention is a *replacement for* the prior-art polysilicon used in a gate.

Appellants submit that *Stein* and *Dawson* considered together do not disclose all of the claim elements and limitations of present claim 20. Therefore appellants submit that the invention claimed in claim 20 is not anticipated by *Stein* and *Dawson*, and therefore that claim 20 is allowable over the prior art of record.

Claim 21 stands rejected as being anticipated by, among others, *Howard*. In the Office Action, a reference is made to *Howard* col. 3, line 31. However, as mentioned above in connection with claim 3, appellants point out that the only place where *Howard* cites the use of platinum silicate (PtSi) is as part of *bottom electrode* 13, directly or indirectly coupled to the substrate 11. *Howard* does not show "said material is platinum silicate" as recited in claim 21, referring to "a diffused gate region formed from a material" as recited in independent claim 20.

Indeed, *Howard* only shows the use of platinum silicate in a bottom electrode 13 of a multi-layer capacitor 10 of Figure 1, not as a gate of a MOSFET. The multi-layer capacitor 10 of *Howard* requires a complicated dual-layer (or triple-layer) dialectric 14 consisting of a leakage prevention layer 18 and a high dielectric layer 17. This usage in *Howard* would if anything teach away from the use of platinum silicate in a more simple structure as disclosed in claim 21 of the present application. Because *Howard* does not teach the use of platinum silicate in a diffused gate region, and further because claim 21 depends from allowable claim 20, appellants submit that claim 21 is allowable over the prior art of record.

Claim 22 stands rejected as being anticipated by, among others, Howard. The Office Action states that the chemical compounds or elements tantalum nitrate (TaN), iridium (Ir), nickel (Ni), and arsenic (As) are disclosed in Howard at col. 3, lines 30-34. As mentioned above in connection with claim 4, appellants have downloaded a softcopy of Howard and performed word searches, but cannot find any reference to any of these compounds or elements in Howard. Therefore appellants submit that the claimed invention of claim 22 is not anticipated by Howard. Since claim 22 depends from allowable claim 20, and further since claim 22 is not anticipated by Howard, appellants submit that claim 22 is allowable over the prior art of record.

Claim 23 stands rejected as being anticipated by, among others,

Serial No. 09/677,698 -16- 42390.P9239

Stein. Since claim 23 depends from allowable claim 20, appellants

submit that claim 23 is allowable over the prior art of record.

Appellants respectfully submit that all the claim elements and

limitations of the pending claims are not disclosed in the combined Stein,

Howard, and Dawson references. Therefore appellants submit that a

proper prima facie case of obviousness has not been made out in the

Office Action mailed 06/04/2003.

Conclusion

Appellants respectfully submit that all claims now pending are in

condition for allowance. Such action is earnestly solicited at the earliest

possible date. If there is a deficiency in fees, please charge our Deposit

Acct. No. 02-2666.

Respectfully submitted,

Date: <u>259Mark 20</u>04

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# IX. Appendix A: Claims Involved in Appeal (Clean Copy)

- 1 1. (Cancelled).
- 2. (Previously presented) An apparatus, comprising:
- 2 a metal-oxide-semiconductor transistor;
- a metallic gate electrode coupled to a diffused gate region of said
- 4 metal-oxide-semiconductor transistor and to a positive voltage source;
- 5 and
- a metallic source electrode and a metallic drain electrode coupled
- 7 to said metal-oxide-semiconductor transistor and to each other and to a
- 8 negative voltage source, wherein said metal-oxide-semiconductor
- 9 transistor includes the diffused gate region formed from material with a
- work function less than 0.56 volts.
- 3. (Previously presented) The apparatus of claim 2, wherein said
- 2 material of said diffused gate region is platinum silicate.

- 4. (Previously presented) The apparatus of claim 2, wherein said
  material of said diffused gate region is selected from the group
  consisting of tantalum nitrate, iridium, nickel, and arsenic.
- 5. (Previously presented) The apparatus of claim 2, wherein said
  metal-oxide-semiconductor transistor includes a heavily-doped
  substrate area.
- 6. (Previously presented) The apparatus of claim 2, wherein said metal-oxide-semiconductor transistor is a p-channel device.
- 7. (Previously presented) The apparatus of claim 2, wherein said metal-oxide-transistor is an n-channel device.
- 1 15. through 19. (Cancelled)

- 20. (Previously presented) An apparatus, comprising:
- a metallic gate electrode to couple to a positive power supply
- 3 voltage;
- a diffused gate region formed from a material whose work
- 5 function is less than minus 0.56 volts;
- 6 a gate insulator area;
- 7 a channel area coupled to said gate insulator area;
- a diffused drain area coupled to said channel area; and
- a diffused source area coupled to said channel area.
- 21. (Previously presented) The apparatus of claim 20, wherein
- 2 said material is platinum silicate.
- 1 22. (Previously presented) The apparatus of claim 20, wherein
- said material is selected from the group consisting of tantalum nitrate,
- 3 iridium, nickel, and arsenic.
- 1 23. (Previously presented) The apparatus of claim 20, further
- comprising a substrate which is heavily-doped.

Serial No. 09/677,698 -20- 42390.P9239



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